



Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it contains a valid OMB control number

Approved for use through 10/31/2002 OMB 0651-0031
U.S. Patent and Trademark Office: U.S. DEPARTMENT OF COMMERCE

Substitute for Form 1449/APT

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(use as many sheets as necessary)

Complete if Known

Application Number	10/540,731
Filing Date	June 24, 2005
First Named Inventor	STEPHANE TAUNIER
Group Art Unit	.
Examiner Name	
Attorney Docket Number	16721-0280 (42528-316590)

Sheet 1 of 1

U.S. PATENT DOCUMENTS

Examiner Initials	Cite No. ¹	U.S. Patent Document		Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code ² (if known)			
EW		4,253,919		Hall et al.	3/3/1981	
		4,687,559		Coburn et al.	8/18/1987	
		5,510,040		Miller et al.	4/23/1996	
		5,071,568		Bennett et al.	12/10/1991	

OTHER INFORMATION - NON PATENT LITERATURE DOCUMENTS

Examiner Initials	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T ²
EW		International Search Report	
		SHIN'ICHI KURANOUCI ET AL., "Study of One-Step Electrodeposition Condition for Preparation of CuIn(Se, S) ₂ Thin Films", <u>Solar Energy Materials and Solar Cells</u> 50, (1998), pp. 31-36. no month	/
		GUILLEN ET AL., "Cathodic Electrodeposition of CuInSe ₂ Thin Films", <u>Thin Solid Films</u> , 195(1991) January, pp. 137-146, Nos. 1/2, Lausanne, CH	
		NAKAMURA ET AL., "Composition Control of Electrodeposited Cu-In-Se Layers for Thin Film CuInSe ₂ Preparation", <u>Solar Energy Materials and Solar Cells</u> 50, (1998), pp. 25-30. no month	

Examiner Signature	/Edna Wong/	Date Considered	08/23/2006
-----------------------	-------------	--------------------	------------

¹Unique citation designation number. ²Applicant is to place a check mark here if English language translation is attached.